The background of the slide is a grayscale micrograph showing a dense network of interconnected, crumpled, and folded sheets of few-layer graphene. The sheets appear as bright, irregular, and somewhat translucent structures against a darker background, highlighting the complex morphology of the material.

Microwave plasma enhanced chemical vapor deposition synthesis and applications of few layer graphene.

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Annick Vanhulsel ^a

Chris Van Haesendonck ^b

^a VITO Materials, Mol, Belgium

^b Laboratory for Solid-State Physics and Magnetism, Heverlee, Belgium



Menu

A taste of graphene

☆☆☆☆☆

Synthesis of few layer graphene

☆☆☆☆☆

Characterization

☆☆☆☆☆

Growth mechanism

☆☆☆☆☆

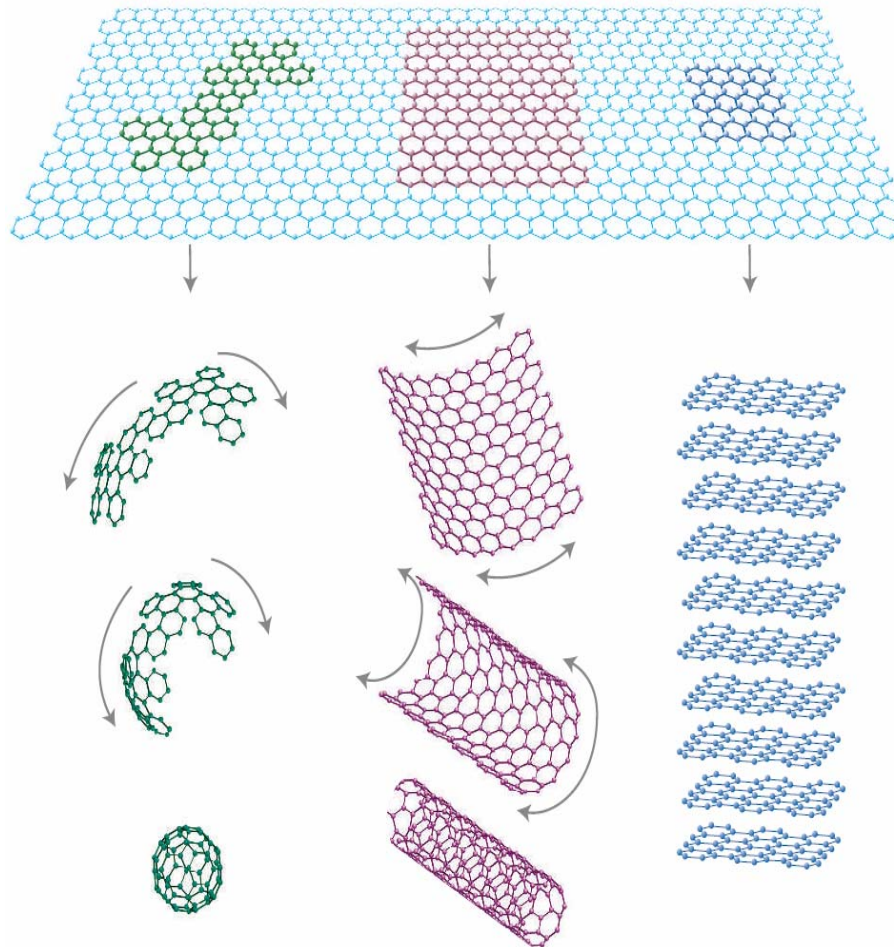
Applications

☆☆☆☆☆

Outlook and conclusions

Introduction

Graphene, the mother of all graphitic allotropes



A.K. Geim and K.S. Novoselov, *The Rise of Graphene*, *Nature Materials*, 6, 183, 2007

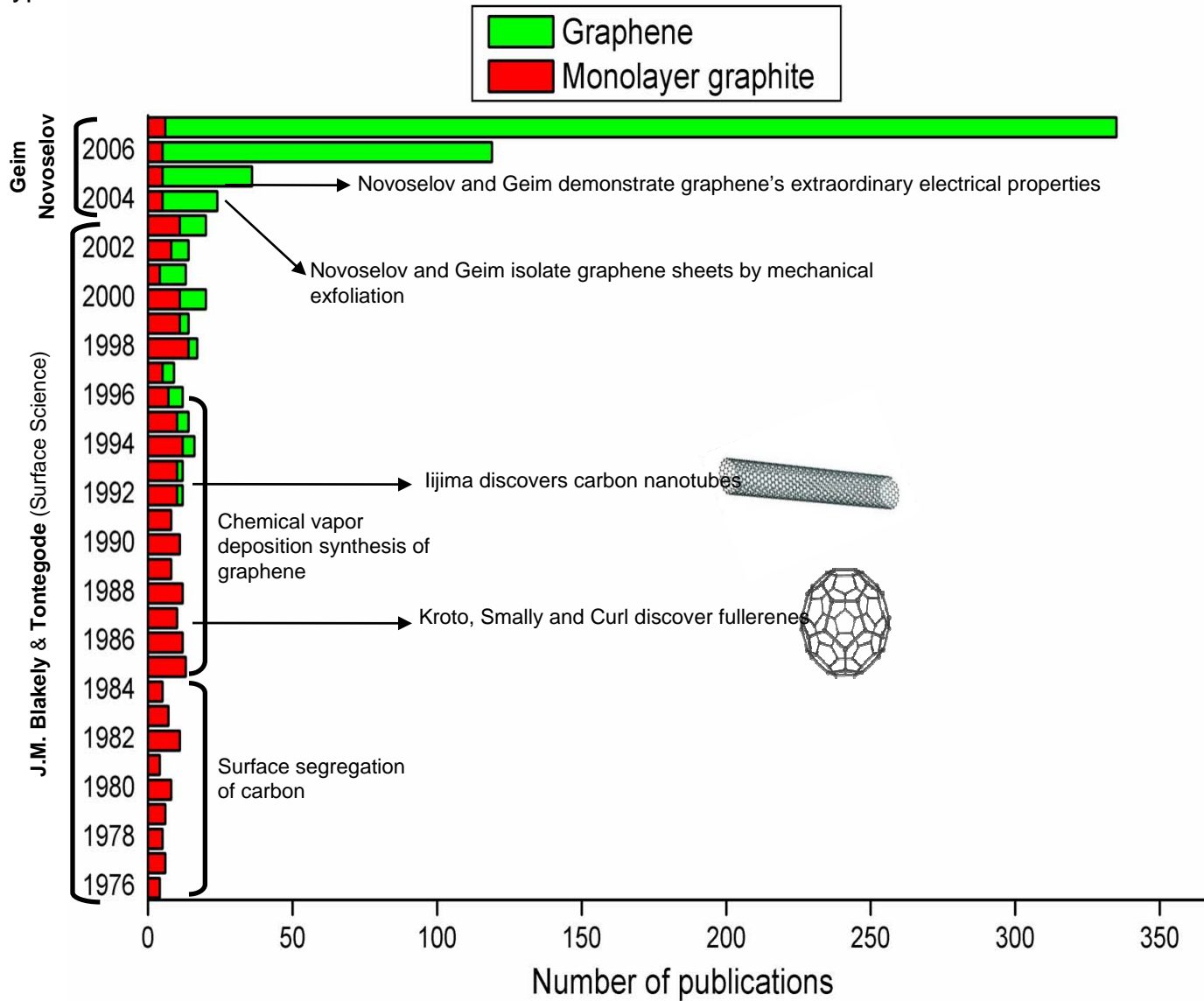


i-SUP, 22-25 April 2008, Bruges

Introduction

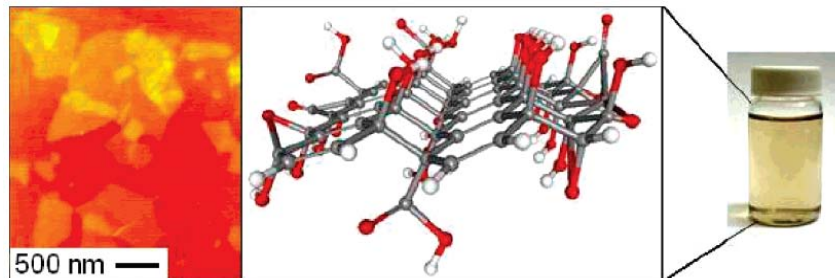
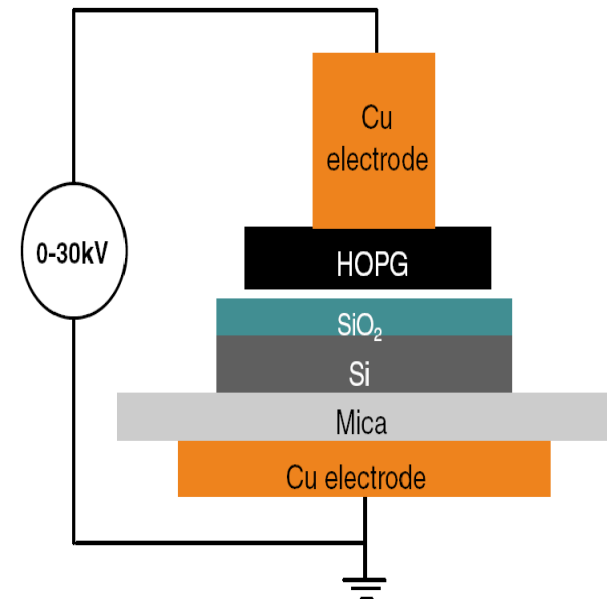
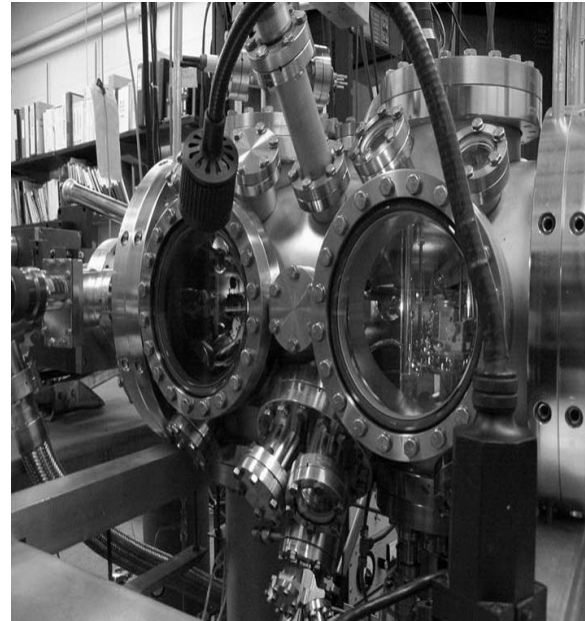
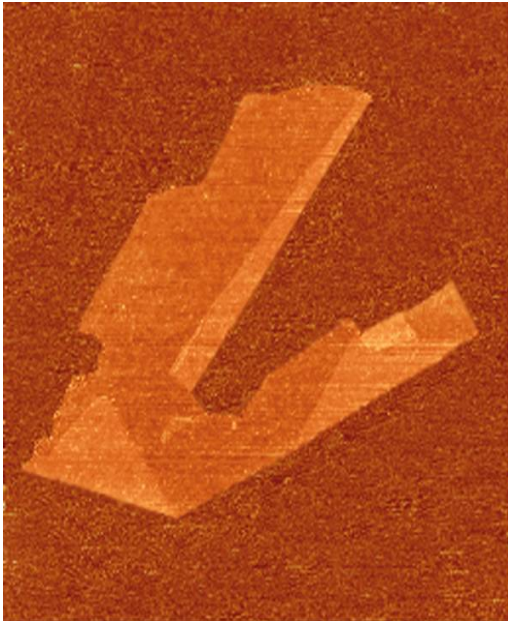


History of a hype



Introduction

Graphene synthesis techniques



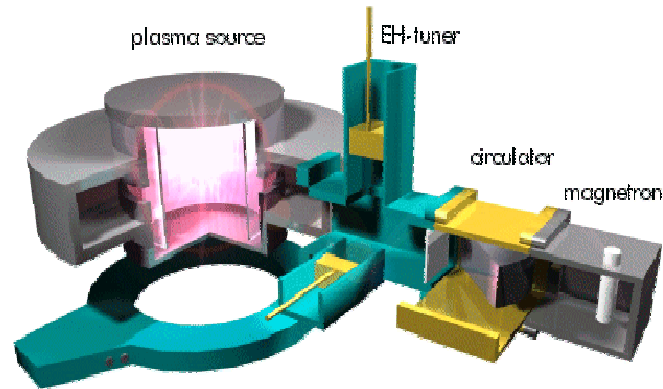
Proc. Natl. Acad. Sci USA, 102, 10451, 2005
Solid State Communications 143, 92-100, 2007
Nanotechnology 18, 135301, 2007
Nano Letters, 7 (11), 3394, 2007

Experimental Setup

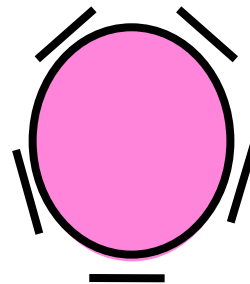


Iplas Cyrannus microwave plasma source

Side view



Top view

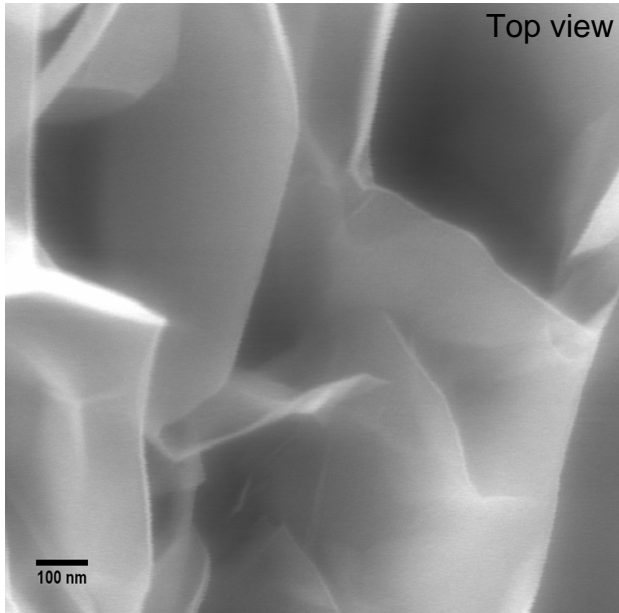


TM 012 mode
 $n_e \sim 10^{13} / \text{cm}^2$

Few layer graphene synthesis



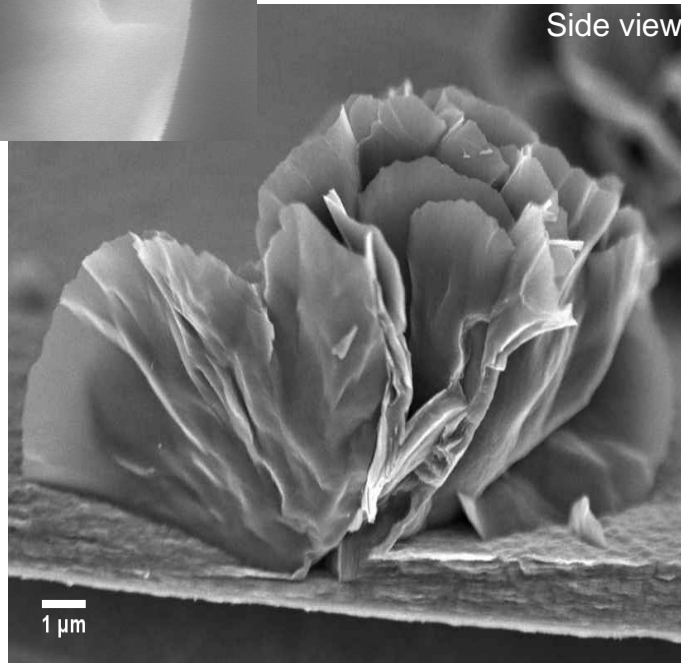
Scanning (left) and transmission (right) electron microscopy



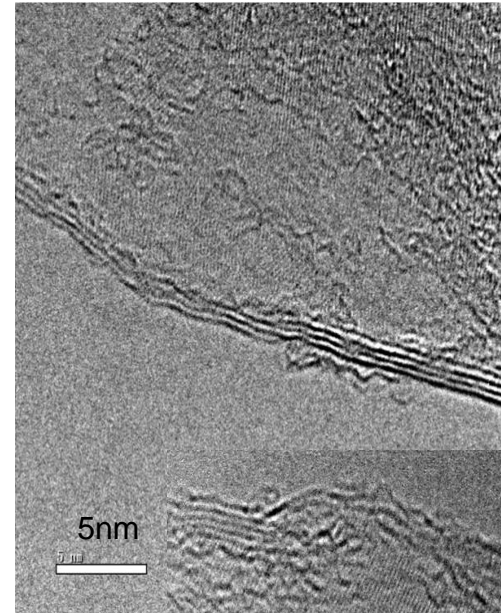
Top view

Conditions:

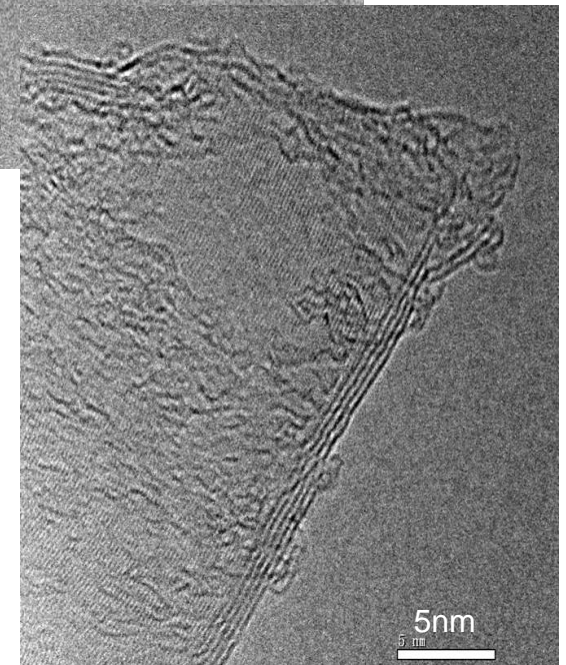
Plasma mode: TM012 mode
Samples: Si/SiO₂, Mo, Pt, Ti,...
Microwave power: 2000 W
Pressure: 40 Torr
Temperature: +/- 1000°C
Bias: 0 V
Gas: CH₄ / H₂ = 1 / 8
total gas flow 200
sccm



Side view



5nm



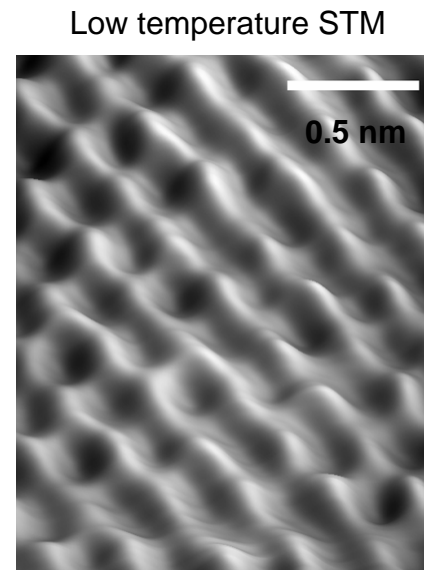
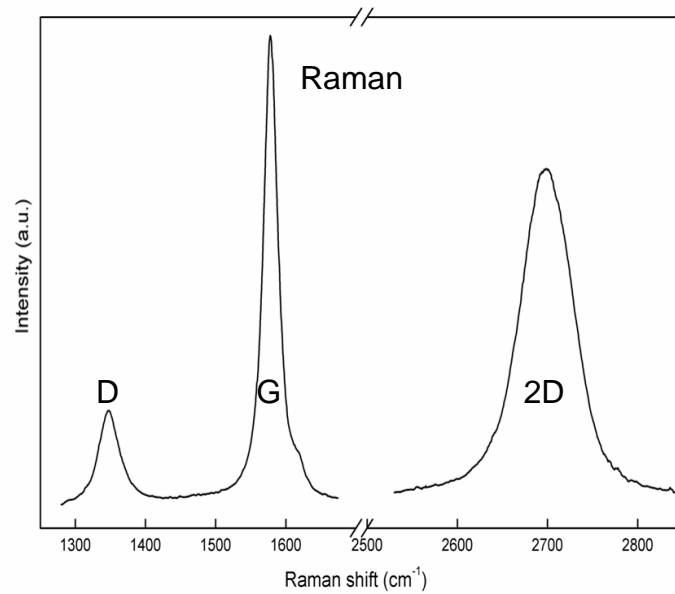
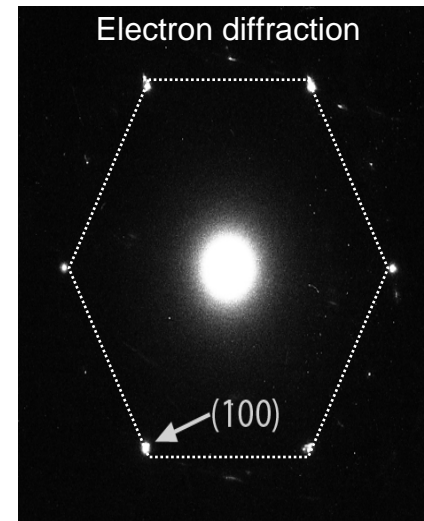
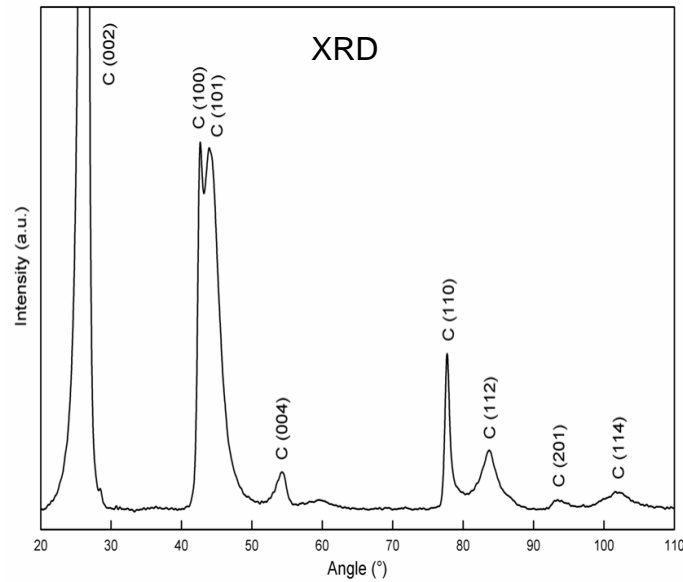
5nm



Few layer graphene synthesis



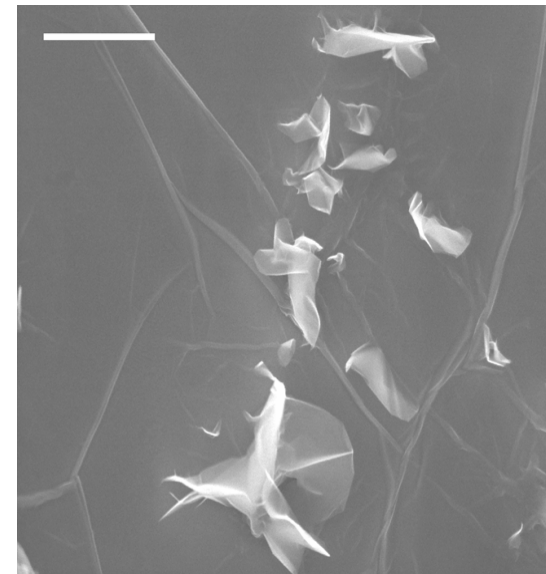
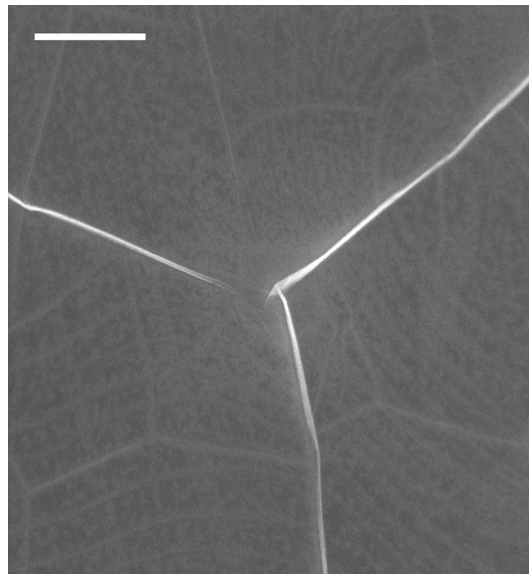
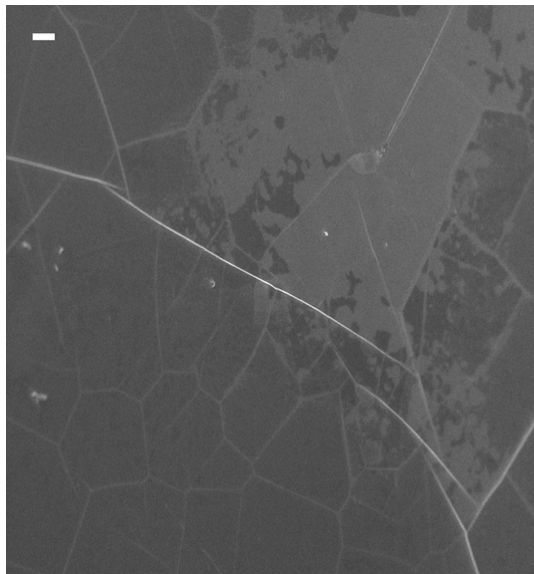
Qualitative analysis



A. Malesevic et al., *Nanotechnology*, in press 2008

Few layer graphene growth mechanism

SEM study



Scale = 1 μm



A. Malesevic et al., *Nanotechnology*, in press 2008

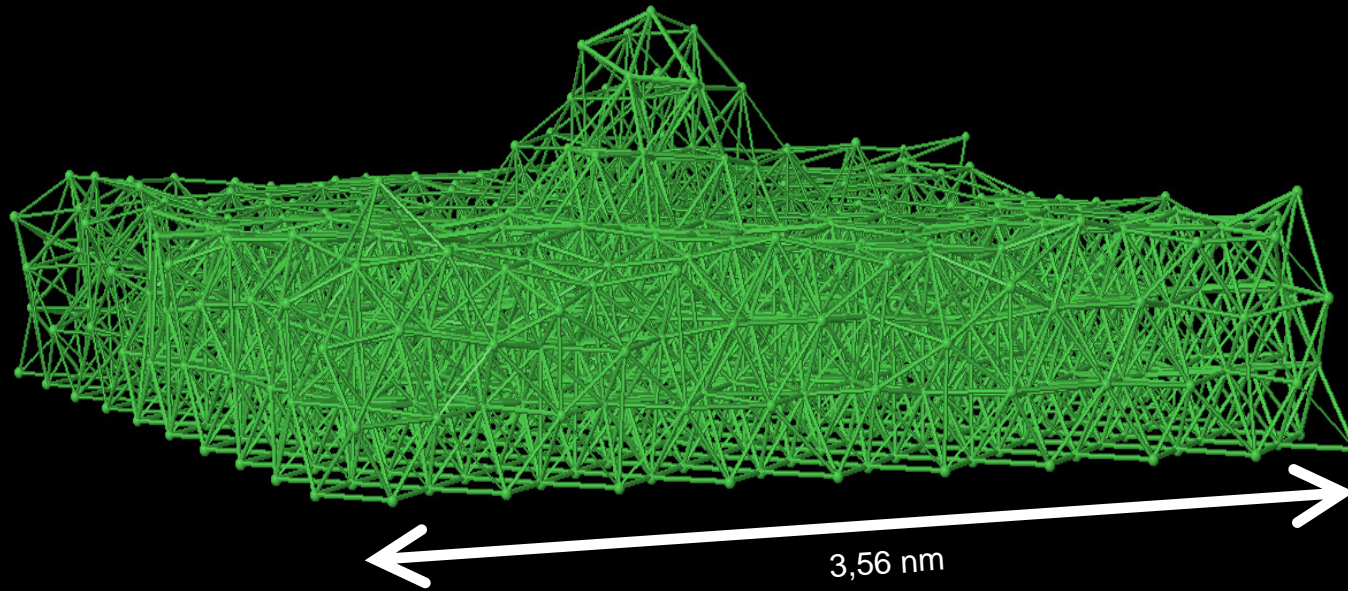
i-SUP, 22-25 April 2008, Bruges

Few layer graphene growth mechanism



Modelling combination of molecular dynamics and monte Carlo simulations

Substrate: Nickel
Cluster: 30 Ni atoms
Temperature: 1100 K
Code: Maruyama

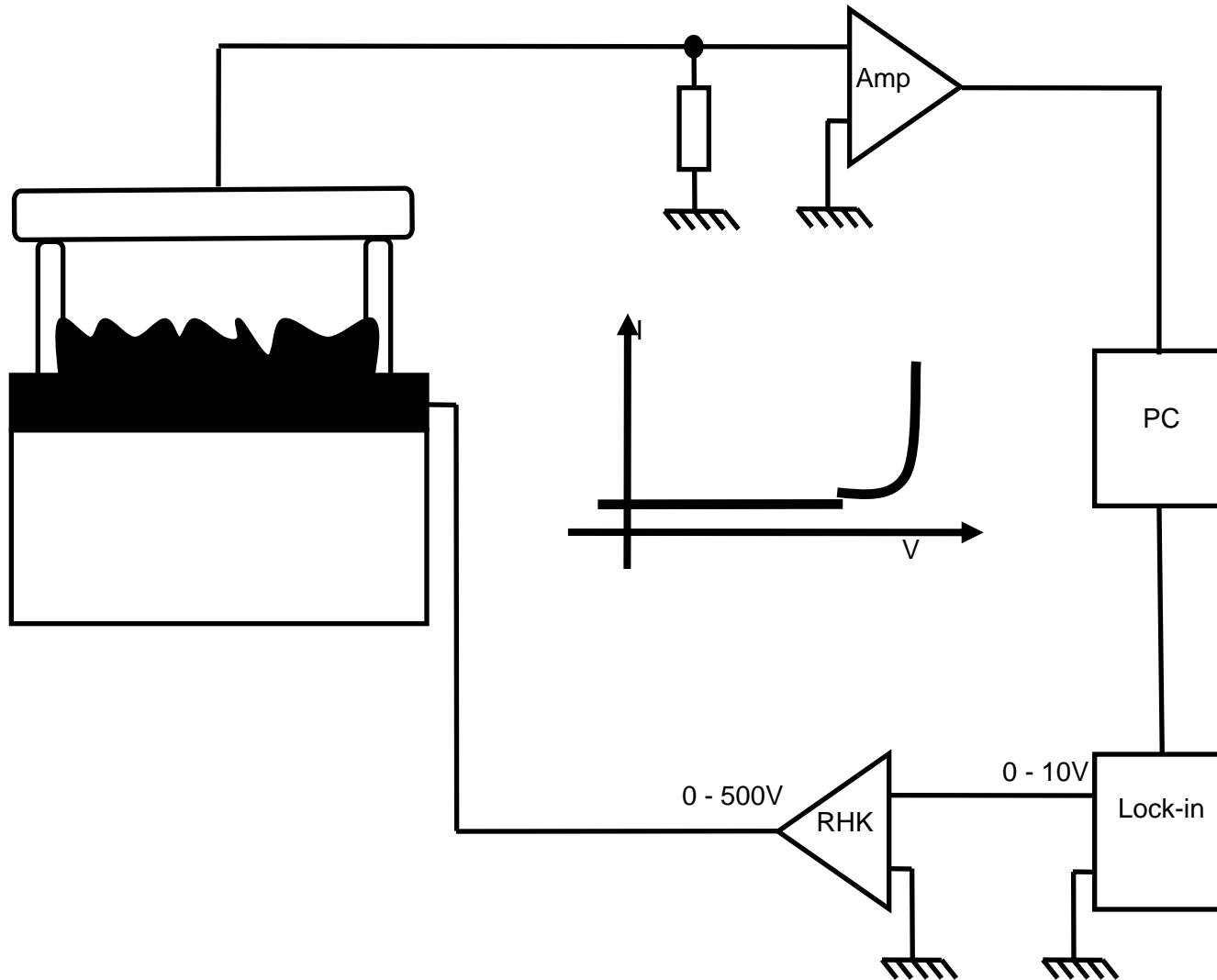


Jmol

Few layer graphene field emission



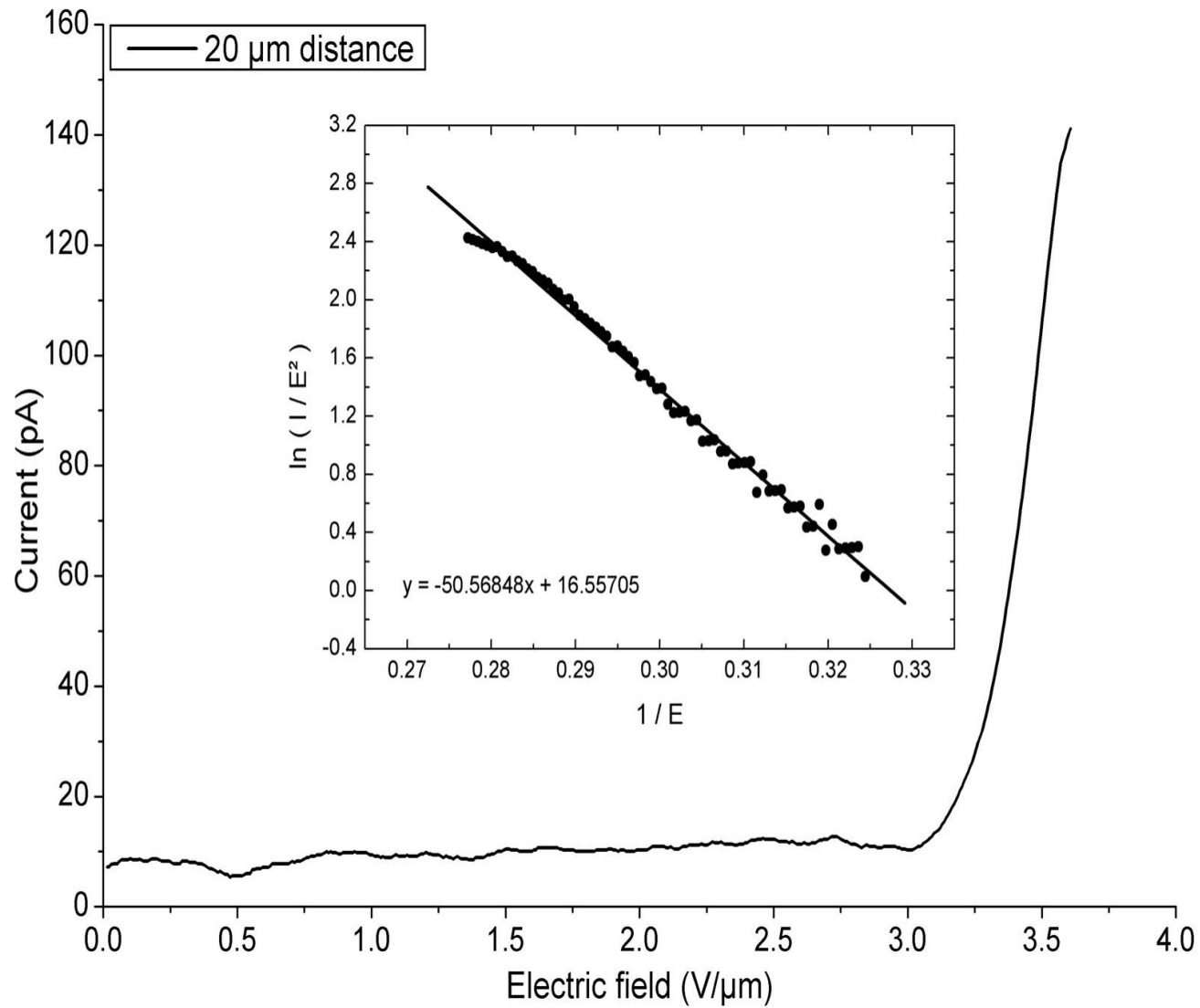
Field emission experimental results



Few layer graphene field emission



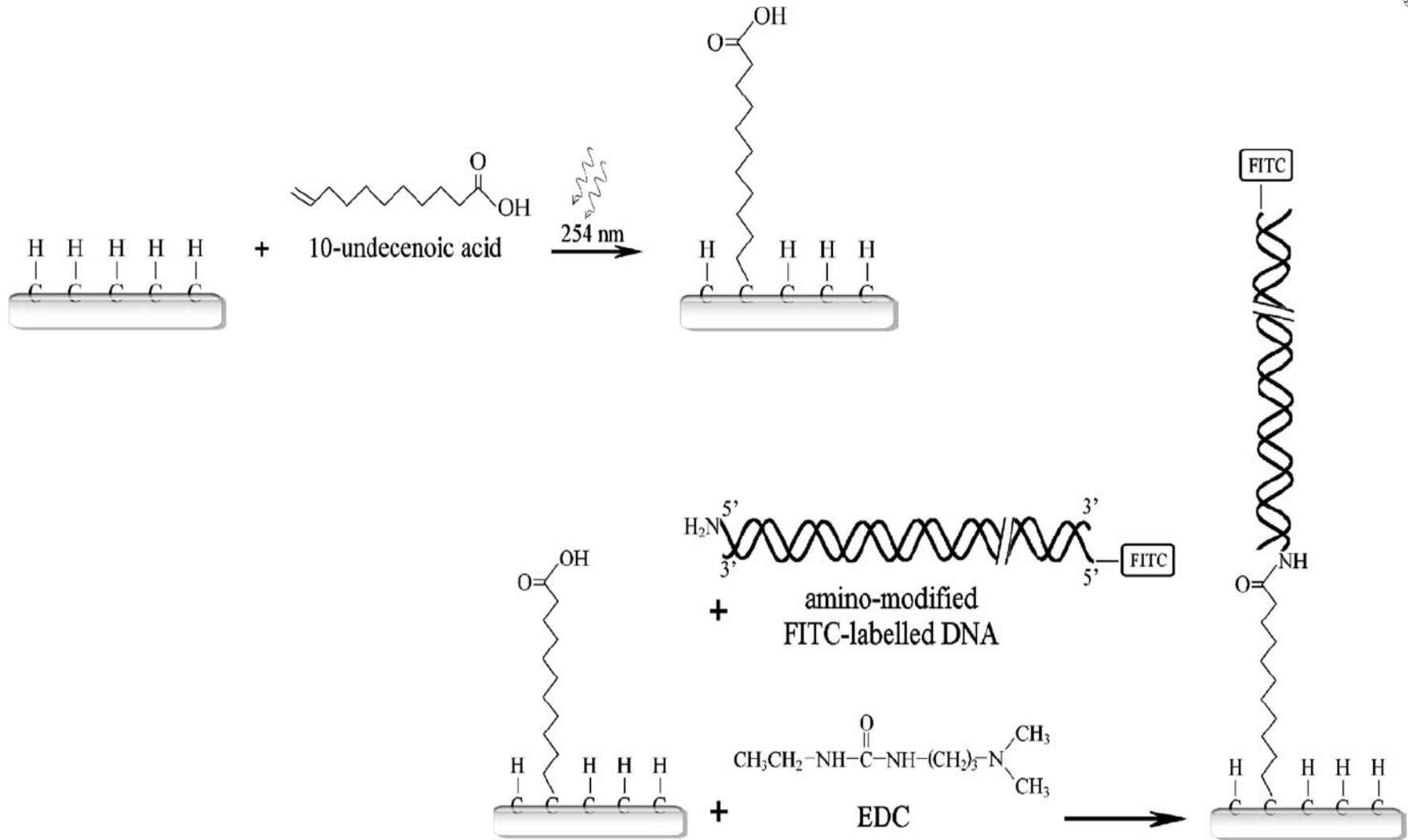
Field emission experimental results



Bioactivation with ss-DNA

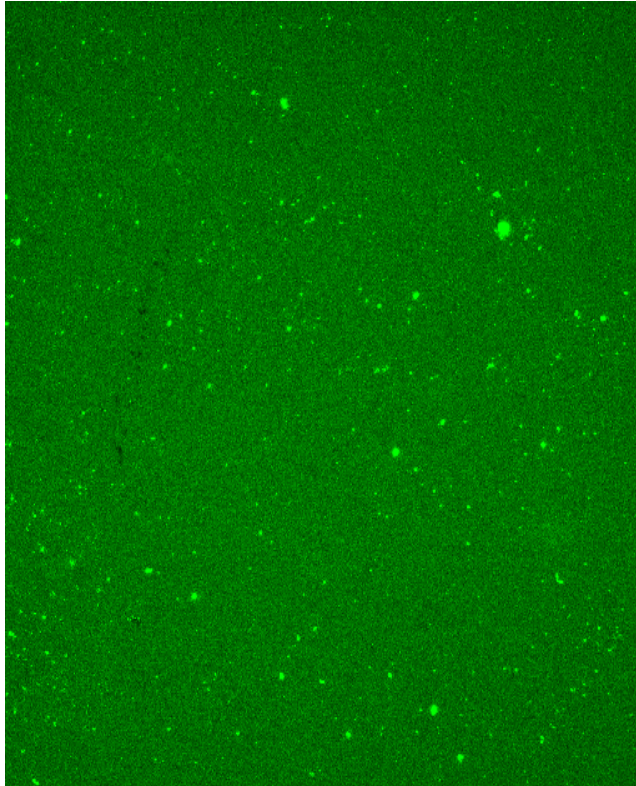


Two-step chemical functionalisation

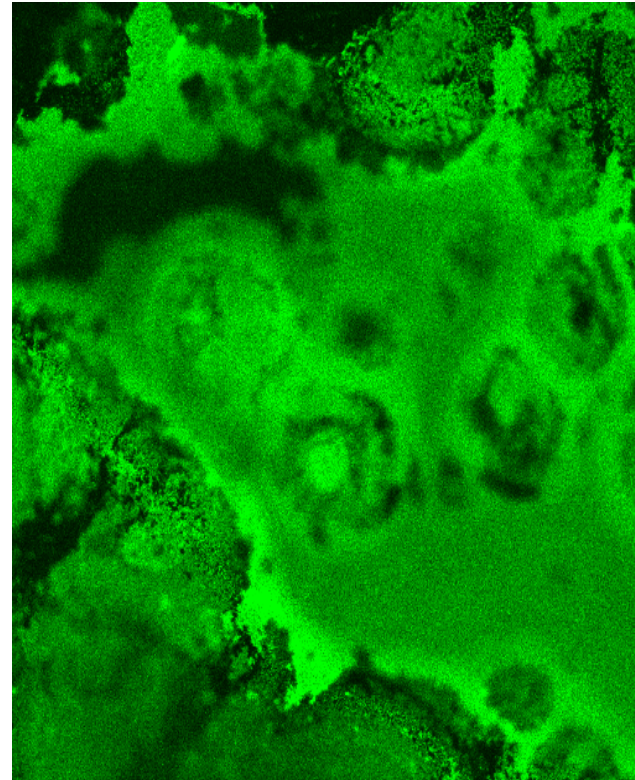


Bioactivation with ss-DNA

Confocal fluorescence microscopy



Si

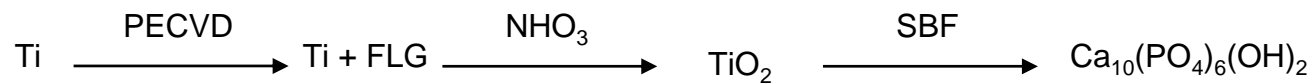
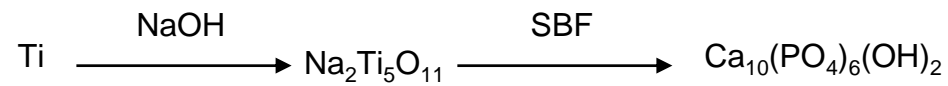
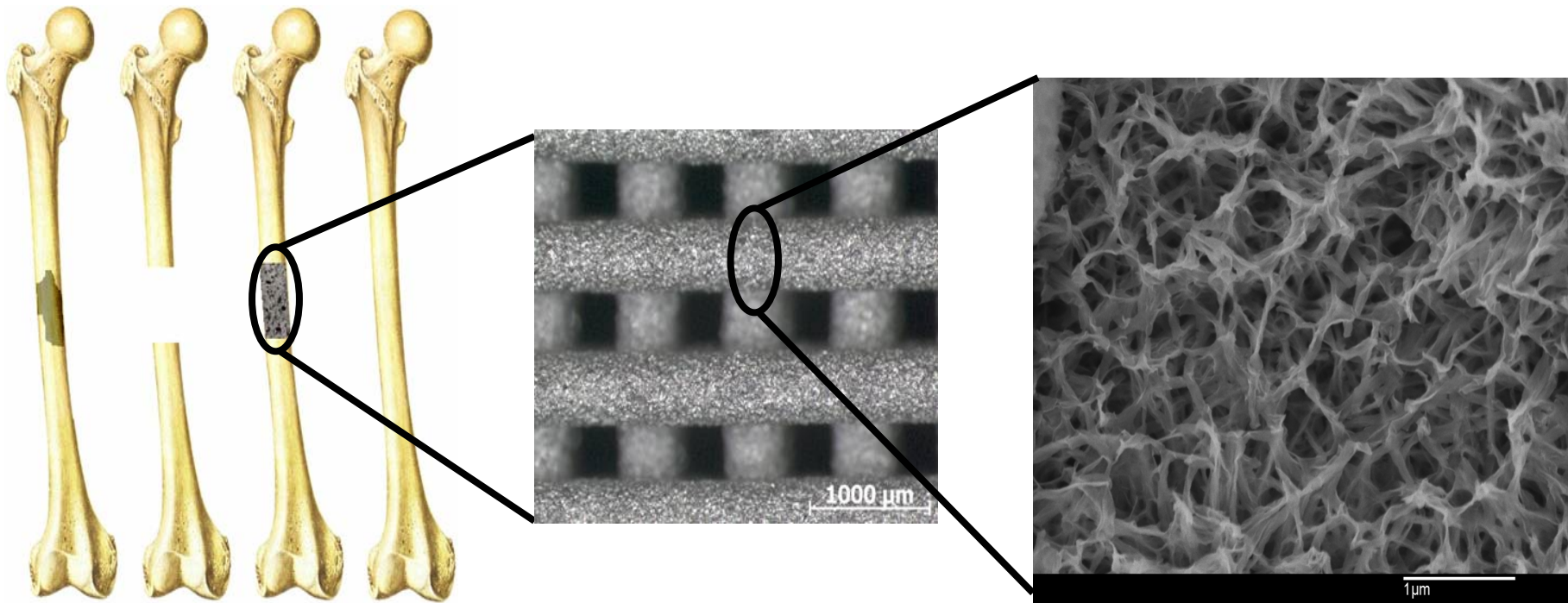


Quartz

Titanium scaffolds for tissue regeneration



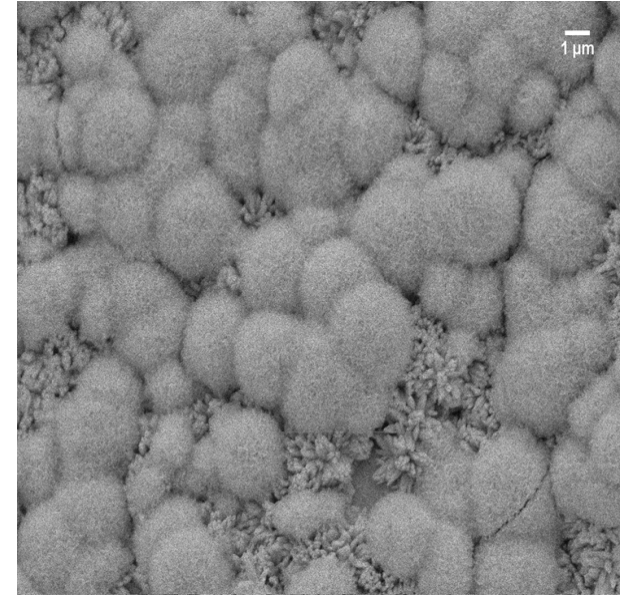
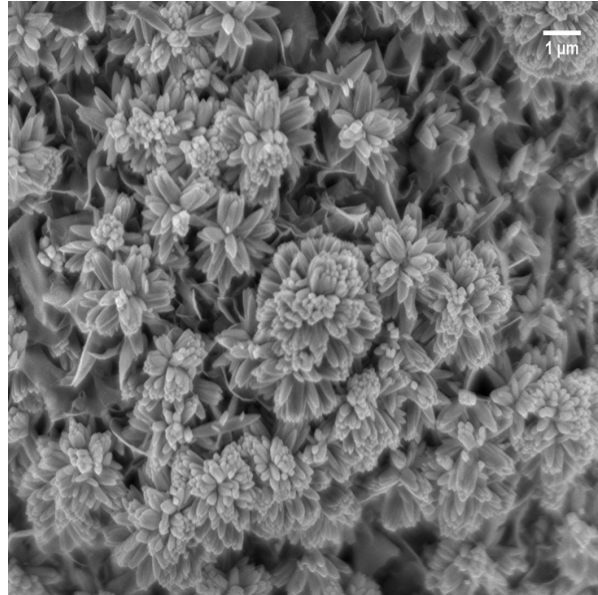
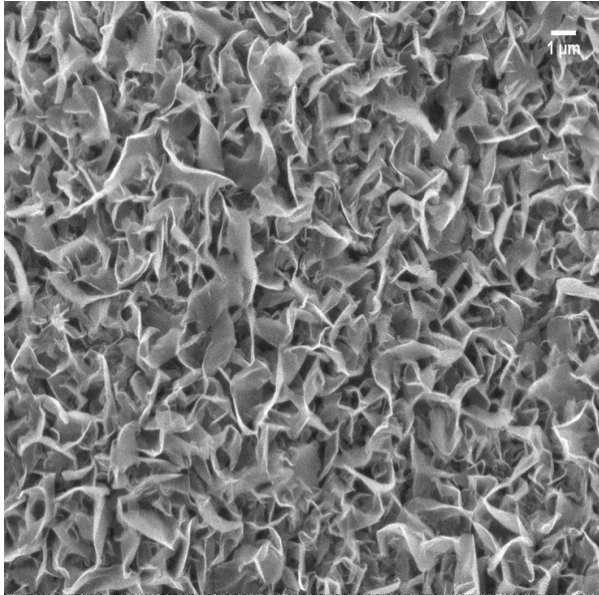
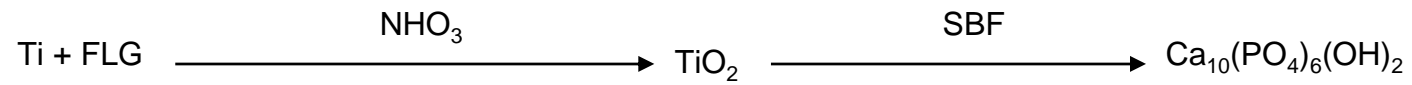
Principle



Titanium scaffolds for tissue regeneration



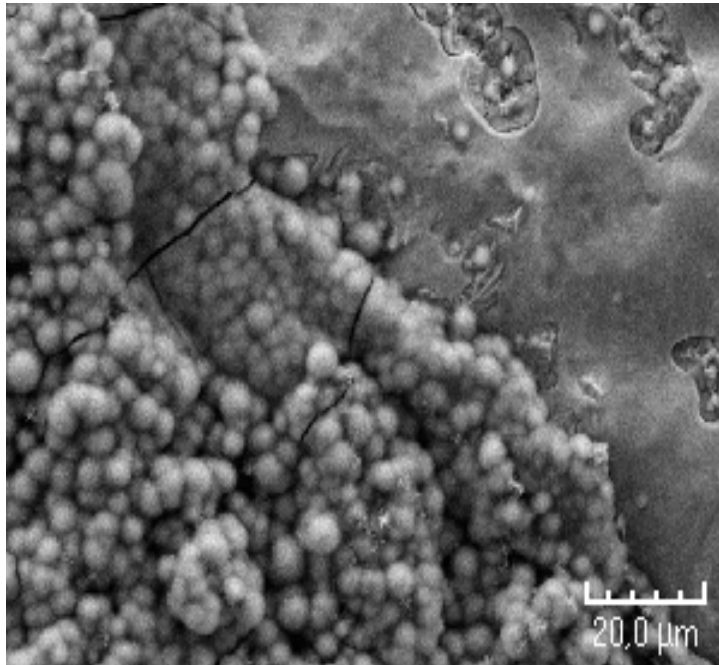
SEM results



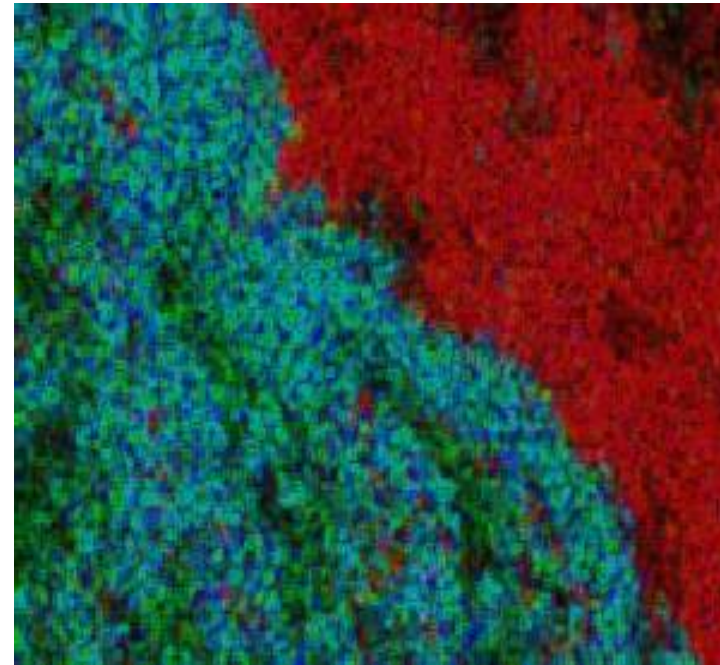
Titanium scaffolds for tissue regeneration



Material analysis



Top view SEM
Morphology



Electron diffraction mapping
RGB Comp Ti-Ca-P

Outlook & Conclusions



MW PECVD Synthesis of FLG:

- * No catalyst required
- * Compatible with industrial techniques

Properties of as grown flakes:

- * 4-6 layers thick
- * Highly crystalline
- * Few defects

Three step growth mechanism

Potential applications:

- * Promising field emission behavior
- * Potential DNA biosensor devices
- * Titanium scaffolds for tissue regeneration



Acknowledgements



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Raymond Kemps^a

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